



# GS600SW Wafer-Level Dispensing Machine RDL First WLP CUF Application

## **Basic Information**

Place of Origin: China
Brand Name: MingSeal
Certification: ISO CE
Model Number: GS600SW

Minimum Order Quantity:

Price: \$1000-\$150000
Packaging Details: WOODEN
Delivery Time: 5-60 days

• Payment Terms: L/C, T/T, D/A, D/P, MoneyGram, Western

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# **Product Specification**

• Condition: New

Voltage: 110V/220V
 Automatic Grade: Automatic
 Warranty: One Year

• Highlight: Wafer Dispensing pick and place pcb machine,

SMT Placement pick and place pcb machine,

PCB smt placement equipment



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## **Product Description**

#### SS101 Wafer-Level Dispensing Machine

#### For Wafer Form Underfill

SS101 is a highly stable and precise wafer level dispensing system which is developed based on Under fill process requirements of RDL First WI P

The equipment meets the needs of the semiconductor industry,can be provided with an automatic wafer loading & unloading system, and can automatically realize functions such as wafer handling, alignment, preheating, operation heating and heat dissipation. It is compatible with international semiconductor communication protocols, and is provided with an AMHS automatic loading & unloading robot interface to match the information management requirements and unmanned management trends.

#### SS101 System Layout

- 1 Loadport & Foup
- 2 Aligner
- 3 QR code scanning station
- Pre-heating station
- SHeat dissipation station
- ©GS600SWA Dispensing Machine work station @GS600SWB Dispensing Machine work station
- **®**Robot Handling module

#### Composition of SS101 Wafer-Level Dispensing System

GS600SW wafer-level dispensing machine  $\times$  2 PC101 wafer loading & unloading machine  $\times$  1

#### **Application Fields**

RDL First WLP CUF Application

#### SS101 Wafer-Level Dispensing Operation Flow



#### **Features and Advantages**

Supporting 8/12-inch wafer dispensing.

Dustproof level 10, meeting the environmental requirements of wafer level packaging.

ESD protection meeting international IEC and ANSI standards.

In the whole process of wafer turnover and operation, the temperature is finely controlled and automatically corrected to meet the CUF process requirements while ensuring the product safety.

The whole-process video monitoring facilitates product turnover, operation process observation, and problem tracing and analysis

# **Technical Specifications**

SS101 system	GS600SWA * 1 ,GS600SWB * 1, PC101 Wafer Handling Machine * 1 (EFEM)	
Application Fields	RDL First WLP, CUFApplication	
Cleanliness Level	Cleanliness of working area	Class 100 (Class 1000 workshop)
		Class 10 (Class 100 workshop)
Product Application Fields	Support for wafer size	φ200mm±0 .5mm, φ300mm±0.5mm
		(Standard model supports 12-inch wafers only)
	Support for wafer thickness	300-2550μ m
	Allowable wafer max. warpage	5mm (as per Robot Finger type)
	range	
	Allowable max.wafer weight	600g (as per Robot Finger type)
	Wafer cassette form	8 inches Open Cassette,12 inches Foup (Standard model
		supports 12-inch wafers only)
PC101(EFEM)	Loading&unloading method	Loadport+Robots
	Pre-Aligner accuracy	Round center correction deviation≤±0 . 1mm Angle correction
		deviation≤±0 .2 °
	Wafer reader	Supports SEMI fonts (Flat or concave/convex surfaces) ,non-
		SEMI fonts
	Preheating temp. range	Room temperature~180°C
	Wafer cooling method	Natural cooling or air cooling
	Transmission mechanisms	X/Y: Linear motor Z: Servo motor&Screw module

	Repeatability	X/Y: ±3μ mZ: ±5μ m
Dispensing Motion System	Positioning accuracy	X/Y: ±10μ m
	Max. movement speed	X/Y: 1000mm/s Z: 500mm/s
	Max. accelerated velocity	X/Y: 1g Z: 0 .5g
Vision System	Camera pixels	130W
	Recognition accuracy	±1 Pixel
	Recognition range	12 × 16mm Recognition range 19 .2 ×25 .6mm
	Light source	Combined three-color light source red, green, white + red
Weighing Calibration System	Weighing accuracy	0.01mg
Chuck Table Load Tray	Vacuum surface flatness deviation	≤30 um
	Heating temp.range	Room temperature~180°C
	Heating temp. deviation	≤±1.5°C
	Repeatability of lifting height	±10 μ m
	Vacuum suction pressure	-70~-85Kpa Settable
Facilities	Footprint (W*D*H)	3075×2200×2200mm(Display unfolded)
	Weight	2.9t
	Power supply	200~240VAC,47~63HZ (Single-phase voltage adaptation power supply)
	Electric current	75A
	Power	16.5KW
	Inhale	(0.5Mpa, 450L/min) ×5 way
	Operating ambient temp.	23°C±3°C
	Relative humidity of working environment	30 ~ 70%



# Mingseal Changzhou Mingseal Robot Technology Co., Ltd.





